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(54) **Title**: A CHEMICAL MECHANICAL POLISHING (CMP) COMPOSITION COMPRISING A GLYCOSIDE

(57) **Abstract**: A chemical mechanical polishing (CMP) composition comprising (A) inorganic particles, organic particles, or a mixture or composite thereof, (B) a glycoside of the formulae 1 to 6 wherein R^1 is alkyl, aryl, or alkylaryl, R^2 is H, X1, X2, X3, X4, X5, X6, alkyl, aryl, or alkylaryl, R^3 is H, X1, X2, X3, X4, X5, X6, alkyl, aryl, or alkylaryl, R^4 is H, X1, X2, X3, X4, X5, X6, alkyl, aryl, or alkylaryl, R^5 is H, X1, X2, X3, X4, X5, X6, alkyl, aryl, or alkylaryl, and the total number of monosaccharide units (X1, X2, X3, X4, X5, or X6) in the glycoside is in the range of from 1 to 20, and (C) an aqueous medium.